

Amendments to the Claims

This listing of claims will replace all prior versions, and listings, of claims in the application.

Listing of Claims:

1. (Currently Amended) A plasma display panel comprising:

a first dielectric layer for covering a display electrode which is formed on a front substrate and which ~~consists of~~ includes a scan electrode and a sustain electrode; and

a second dielectric layer for covering a data electrode formed on a back substrate, wherein

at least one of ~~a periphery of~~ the first dielectric layer and ~~a periphery of~~ the second dielectric layer in plane view has a corner with a radius of curvature of other than zero [[0]].
2. (Original) The plasma display panel according to claim 1, wherein at least one of the first dielectric layer and the second dielectric layer is formed by firing a precursor material layer transferred from a transfer film.
3. (Original) The plasma display panel according to claim 1 or 2, wherein at least one of the first dielectric layer and the second dielectric layer is formed by firing a precursor material layer having photosensitivity.
4. (New) A manufacturing method of a plasma display panel, comprising the steps of:

forming a first dielectric layer for covering a display electrode which is formed on a front substrate and includes a scan electrode and sustain electrode; and

forming a second dielectric layer for covering a data electrode formed on a back substrate, wherein

at least one of the first dielectric layer and the second dielectric layer in plane view has corners with a radius of curvature of other than zero.

5. (New) The manufacturing method of a plasma display panel of claim 4, wherein at least one of the first dielectric layer and the second dielectric layer is formed by firing a precursor material layer printing a dielectric paste material on the substrate.

6. (New) The manufacturing method of a plasma display panel of claim 4, wherein at least one of the first dielectric layer and the second dielectric layer is formed by firing a precursor material layer transformed from a transfer film.

7. (New) The manufacturing method of a plasma display panel of claim 5 or 6, wherein at least one of the first dielectric layer and the second dielectric layer is formed by firing a precursor material layer made of a photosensitive dielectric material.

8. (New) The manufacturing method of a plasma display panel of claim 5 or 6, wherein at least one of the first dielectric layer and the second dielectric layer has round corners by use of paste fluidity after forming a precursor material layer.

9. (New) The manufacturing method of a plasma display panel of claim 5 or 6, wherein at least one of the first dielectric layer and the second dielectric layer has round corners by press cutting the round corners after forming a precursor material layer.

10. (New) The manufacturing method of a plasma display panel of claim 7, wherein at least one of the first dielectric layer and the second dielectric layer has round corners by photolithography after forming a precursor material layer.